

**CPC****COOPERATIVE PATENT CLASSIFICATION****C09G****POLISHING COMPOSITIONS OTHER THAN FRENCH POLISH;  
SKI WAXES****C09G 1/00****Polishing compositions** (French polish [C09F 11/00](#); detergents [C11D](#))**C09G 1/02**

- containing abrasives or grinding agents {(abrasives as such [C09K 3/14](#); polishing of semi-conductors [H01L](#))}

**C09G 1/04**

- Aqueous dispersions ([C09G 1/02](#) takes precedence)

**C09G 1/06**

- Other polishing compositions

**C09G 1/08**

- . based on wax

**C09G 1/10**

- . . based on mixtures of wax and natural or synthetic resin

**C09G 1/12**

- . . . mixtures of wax and silicon-containing polycondensates

**C09G 1/14**

- . based on non-waxy substances

**C09G 1/16**

- . . on natural or synthetic resins

**C09G 1/18**

- . . on other substances

**C09G 3/00****Ski waxes**